



PATENT

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Heday
8/9/01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANTS: BRUNNER ET AL-1

SERIAL NO.: 09/425,694 ✓

EXAMINER: C. BROWN

FILED: OCTOBER 22, 1999

GROUP: 1765

TITLE: PROCESS FOR THE WET CHEMICAL TREATMENT OF
SEMICONDUCTOR WAFERS

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

ATTN: BOX FEE AMENDMENT
Assistant Commissioner of Patents
Washington, D.C. 20231

RECEIVED
AUG 09 2001
TC 1700

Dear Sir:

In response to the Non-Final Office Action dated March 12, 2001, with the time for reply having been extended for two months or until August 12, 2001, please amend the above-identified patent application as follows:

IN THE CLAIMS:

Please amend claim 1, and claim 11, as follows. A Marked-Up Version of these amended claims is attached hereto.

Claim 1 (Three Times Amended):

A process for the wet chemical treatment of semiconductor